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	Complete If Known		
Application Number 10/602,716-Conf. #9955			
Filing Date	June 25, 2003		
First Named Inventor	Chandra Mouli		
Art Unit	2811		
Examiner Name	D. Kang Colleen matthews		
Attorney Dockel Number	M4065.0904/P904		

U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite No.'	Document Number Number-Kind Code ² (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appoar
CAM	AA	2002/0190287	12/19/2002	Mann et al.	

FOREIGN PATENT DOCUMENTS						
Examiner Initials*	Cite No.1	Foreign Patent Document Country Code ³ -Number ⁴ -Kind Code ⁵ (if known)	Publication Date MM-DD-YYYY	Name of Patentce or Applicant of Cited Document	Pages, Columns, Unes, Where Relevant Passages or Relevant Figures Appear	۲٥
CAM	BA	EP 0 798 785	10/01/1997			
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NON PATENT LITERATURE DOCUMENTS				
Examiner Initials	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	ال	
CAM	CA	Kim, K.T. et al. – "Tungsten Silicide/Titanium Nitride Compound Gate," June 4, 1990, Symposium on VLSI Technology, Honolulu, June 4-7, 1990, New York, IEEE, US, pgs 115-116.		
CHAU	СВ	Long, Wei et al. – "Dual-Material Gate (DMG) Field Effect Transistor," May 1999, IEEE Transactions on Electron Devices, IEEE Inc. New York, US, pgs. 865-870.		
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CAM	CD	Yagishita, Atsushi et al. – "Dynamic Threshold Voltage Damascene Metal Gate MOSFET (DT-DMG-MOS) Technology for Very Low Voltage Operation of Under 0.7 V," IEEE Transactions on Electron Devices, IEEE Inc. New York, US, vol. 49, no. 3, March 2002, pges. 422-428.		
CIPA	CE	International Search Report dated 11/30/2004.		

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12/06/2007

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